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STATEMENT BY APPLICANT**

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| Application Number | National Stage Entry of PCT/JP2004/004938 |
| Confirmation Number | Not yet assigned |
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| First Named Inventor | Yasuki KIMURA |
| Art Unit | Not yet assigned 1763 |
| Examiner Name | Not yet assigned Olsen |
| Attorney Docket Number | Q87054 |

Sheet 1 of 1

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| Examiner Initials* | Cite No. ¹ | Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published. | Translation ⁴ |
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Examiner Signature

Allan Olsen

Date Considered

3-20-06

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